

Sunday, 29th Sept

17:00	Registration
19:00	Welcome drink & welcome dinner

Monday, 30th Sept

8:45	Opening of JVC-19
	Session 1
	David N. Ruzic, Illinois Plasma Institute, USA
9:00	Controlling the Energy and Species in PVD: HiPIMS with Cathode Reversal,
	Plenary
9:45	Martin Čada, Czech Republic
	HiPIMS with controlled arc ignition: hybrid plasma deposition technique for
	hard coatings, Invited
	Miha Čekada, Slovenia
10:15	Property variation of hard coatings deposited in industrial deposition
	systems, Oral
	Jozef Novák, Slovakia
10:35	Focused Ion Beam technology as an excellent tool for integration of the
	three dimensional GaP nanocone onto Single Mode Optical Fibre, Oral
10:55	Coffee break

	Session 2
11:30	Attila Csík, Hungary
11.50	Surface coating layers for sensors and biomedical applications, Invited
	Matej Drobnič, Slovenia
12:00	Effect of LCO2 on TiAIN hard coating wear behavior at elevated
	temperatures, Oral
	Klára Hajagos-Nagy, Hungary
12:20	Non-equilibrium solubility of Cu in α -Mn structure – microstructure and
	growth of α-Mn(Cu) films, Oral
	Nikolina Novosel, Croatia
12:40	Complex magnetic and transport phenomena in nanocrystalline gadolinium
	doped manganite CaMnO3, Oral
13:00	Lunch break



	Session 3
	Peter Siffalovic, Slovakia
15:00	In-Situ Techniques for Perovskite Layer Growth Monitoring: X-ray Scattering
	and Photoluminescence, Invited
	Jaroslav Kousal, Czech Republic
15:30	Plasma-Assisted Vapour Thermal Deposition for Controlled Deposition of
	Nanocomposites, Oral
15:50	Vedran Đerek, Croatia
15.50	Optically driven thin film OECT electrochemical sensor, Oral
	Rainer Hahn, Austria
16:10	title: Assessing and enhancing fracture toughness of hexagonal diboride
	coatings, Invited
16:40	Coffee break
17:10	Poster session 1
19:00	Dinner

Tuesday, 1st Oct

	Session 4
	László Óvári, University Szeged & Extreme Light Infrastructure ALPS,
9:00	Hungary
	2D Boron Carbon Nitride structures: from synthesis to application, Plenary
9:45	Petr Vašina, Czech Republic
5:45	Me-B-C coatings - hard and fracture resistant material, Invited
	Žan Gostenčnik , Slovenia
10:15	Refractory high-entropy nitride coatings deposited by reactive direct current
	magnetron sputtering, Oral
10:35	Erzsébet Dodony, Hungary
10:35	EDIC intensity correction of electron diffraction, Oral
10:55	Coffee break



	Session 5
11:30	Pavol Noga , Slovakia Ion beams for high fluence irradiation testing and characterization of materials, Invited
12:00	Zoltán Száraz , Slovakia Ion beam irradiation and analysis of materials for radiation environments, Oral
12:20	Milena D. Majkić, Serbia Mechanism of nanostructure formation on metal surface by an impact of slow highly charged ions under arbitrary angle of incidence, Oral
12:40	Andrea Schulze, Germany Enhancing Magnetic Sensing & Next-Gen AR Devices - Superior Performance with Ion Beam Processing (scia systems – sponsor presentation)
13:00	Lunch

	Session 6
15:00	Jordi Sancho Paramon, Croatia
15.00	Semi-continuous metal films as building blocks for optical coating, Invited
	Pavel Čurda, Czech Republic
15:30	ITO nanostructures for label free electro-optical modulated LMR sensing,
	Oral
	Aleš Omerzu, Croatia
15:50	Thin ZnO films prepared by plasma-enhanced atomic layer deposition for
	enhanced photocatalytic applications, Oral
	Róbert Kun, Hungary
16:10	Nanomechanical characterization of solid-state Li-ion battery components,
	Invited
16:40	Coffee break
17:10	Poster session 2
19:00	Dinner



Wednesday, 2nd Oct

	Session 7
	María C. Asensio, Materials Science Institute of Madrid, Spain
9:00	Discovery of advanced materials using artificial intelligence methods and
	advanced characterization techniques, Plenary
	Michael Tkadletz, Austria
9:45	Microstructural Design of Cathodic Arc Deposited fcc-TiAlN Coatings: A Path
	Toward Sustainable Hard Coatings, Invited
10.15	Rok Zaplotnik, Slovenia
10:15	Novel plasma-supercavitation technology for water cleaning, Oral
	Gregor Primc, Slovenia
10:35	Combination of advanced oxidation technologies for removal of
	micropollutants, Oral
10:55	Coffee break

	Session 8
11:30	Matjaž Panjan, Slovenia
	Unraveling plasma self-organization of magnetron sputtering discharges,
	Invited
	Nina Recek, Slovenia
12:00	Upscaling the plasma reactor for the treatment of seeds and seed-borne
	toxins in agriculture use, Oral
	Ardita Kurtishaj Hamzaj, Slovenia
12:20	Hydrogen interaction and oxide permeation barrier formation in B2-ordered
	Fe-Al intermetallic alloy, Oral
12:40	Iveta Ukropcová, Czech Republic
	3D Printing of Semiconductors using Electron Tweezers, Oral
13:00	Lunch
	Excursion / City tour - Split sightseeing
15:00	&
	Conference dinner at konoba Rudine



Thursday, 3rd Oct

	Session 9
9:00	Judith L. Driscoll, University of Cambridge, United Kingdom
	Challenges and Solutions of Oxides for Future AI Hardware, Plenary
	Nives Štrkalj, Croatia
9:45	Nanoscale Ferroelectricity and Electrochemical Dynamics in Hafnia-Based
	Films, Invited
	Ján Šoltýs , Slovakia
10:15	Fabrication of NbTiN superconducting nanowire single-photon detector,
	Oral
10:35	Karel Mašek, Czech Republic
10:35	Structure and growth of cobalt oxide epitaxial layers, Oral
10:55	Coffee break

	Session 10
11:30	Barbara Šetina Batič, Slovenia Microbiologically induced corrosion of power plant steel components, Invited
12:00	Kinga Kutasi, Hungary Alginate-stabilized colloidal ZnO NPs for biomedical applications, Oral
12:20	Nepal C. Roy , Belgium Atmospheric plasmas for depositing sulfonated plasma-polymerized films for use in liquid contacts, Oral
12:40	Mark Zver, Slovenia Plasma-generated vacuum-UV radiation for inactivation of viruses in water, Oral
13:00	Lunch



	Session 11
15:00	Željko Skoko , Croatia
	Revealing nanoscale mechanism in the jumping crystals, Invited
	Lucie Janů, Czech Republic
15:30	Radical-assisted covalent binding of biomolecules to amine plasma
	polymers, Oral
	Ida Delač, Croatia
15:50	Exploring the effects and stability of organic molecule modifications on
	CVD-synthesized monolayer MoS2, Oral
16:10	Closing remarks
16:20	Coffee break
19:00	Dinner



Monday 30th Sept

17:10-19:00

Poster session 1		
P1	Changhwan Choi, Korea	
	ALD HfZrOx and InGaOx Thin Films for Flash Memory Application	
P2	Robert Peter, Croatia	
	Photocatalytic activity of TiO2 thin films embedded with Cu nanoparticles	
	prepared by atomic layer deposition technique	
Р3	Aljaž Drnovšek, Slovenia	
	High-Temperature Tribology of Multilayered CrN/(Cr,V)N/VN Protective	
	Coatings	
P4	Vedran Brusar, Croatia	
	Pressure dependent nonlinear spectral broadening of ultrashort laser pulses	
	in hollow-core fiber (HCF)	
P5	Iva Šrut Rakić , Croatia	
	Monolayer MoS2 growth on a pre-patterned substrate as a way to induce	
	strain	
	Andrea Jurov, Slovenia	
P6	Characterization of Alumina Scales on Fe-Al Alloys: Enhancing High-	
	Temperature Hydrogen Permeability Resistance	
P7	Davor Čapeta, Croatia	
F/	High resolution, compact Raman spectrometer based on CMOS camera	
	Julio Car, Croatia	
P8	Determination of dielectric functions of colloidal silver nanoparticles in LSPR	
	relevant wavelength range	
	Filip Ferenčík, Slovakia	
Р9	Effect of Sputtering Power on Low Concentration Impurities in Binary Oxides	
	for Semiconductor Applications: A ToF-ERDA Characterization Study	
	Iva Šarić Janković , Croatia	
P10	Low-energy ion bombardment induced reduction of TiO2 grown by Atomic	
	Layer Deposition	
	Karmen Kapustić, Croatia	
P11	Visualizing intercalation of 2D material using AFM based techniques: MoS2	
	on graphene/Ir(111) case study	
	Nikša Krstulović, Croatia	
P12	UV and solar-driven photocatalysis of organic dyes using ZnO-Ag	
	heterojunction nanoparticles synthesized by one-step laser synthesis in	
	water	
P13	Karolina Pietrzak, Croatia	
	Application of electrochemical impedance spectroscopy in studying the	
	mechanism of metal oxide nanoparticles used in ion-selective electrodes	



P14	Šárka Zuzjaková, Czech Republic High entropy nitrides: High temperature study of Cr–Hf–Mo–Ta–W–N thin films
P15	Zsolt Fogarassy , Hungary Structural investigation of the heat-treated Ti/Al/TiN/Au contact layer on n-GaN - role of TiN
P16	Miklós Serényi, Hungary On the challenges in reactive HiPIMS co-sputtering of Y and Ti for oxide layers
P17	Béla Pécz , Hungary Advanced structural characterization of Gallium Oxide by transmission electron microscopy

Tuesday 1st Oct

17:10-19:00

	Poster session 2
P1	Lucija Krce, Croatia
	PET surfaces treated with atmospheric pressure plasma jet and enhanced
	with ZnO nanoparticles: characterization and antibacterial activity
P2	Damir Dominko, Croatia Collective states driven for guest from the equilibrium
P3	Collective states driven far away from the equilibrium
	Miran Mozetič, Slovenia
	Characterization of low-pressure gaseous plasmas by optical emission
	spectroscopy
P4	Maja Mičetić, Croatia
	Synthesis and properties of Ge-based core-shell quantum structures
P5	Mario Rakić, Croatia
	Femtosecond engraving computer-generated holograms
P6	Rafaela Radičić, Croatia
	Fabricating PET/ZnO composite assisted by RF plasma processing
P7	Tihomir Car, Croatia
	Silver nanoparticles in SiC matrix
P8	Zsolt Fogarassy, Hungary
	Technological applicability of VO2 layers prepared with different
	approaches
	Krešimir Salamon, Croatia
Р9	Grazing incidence high-energy heavy ion irradiation for surface
	nanopatterning
P10	Tímea Hegedűs, Hungary
	Pt nanoparticles on inert h-BN support: investigation of the CO2
	hydrogenation mechanism on the surface level



P11	Ildiko Cora, Hungary
	In situ TEM examination of the monoclinic VO2 thin layer phase
	transformation to tetragonal VO2
P12	Dimo Yosifov, Canada
	Python Modeling of Beamline Vacuum System
P13	Klára Hajagos-Nagy, Hungary
	The effect of impurities on the structure and mechanical properties of
	CoCrCuFeNi alloy films
P14	Pranjali Jadhao, Czech Republic
	Direct growth and application of 2D single crystals of MXenes
P15	Ivna Kavre Piltaver, Croatia
	Enhanced Photocatalytic Activity of ZnO Films with Fe2O3 Intermediate
	Layers for Efficient Water Purification
P16	Alenka Vesel, Slovenia
	Influence of chitosan-coated urinary catheters on adhesion of urethral cells
P17	Martin Vičar, Czech Republic
	New stable ionization vacuum gauge as the transfer standard
P18	Marcell Gajdics, Hungary
	GaON thin films prepared by reactive sputtering of a liquid Ga target